

## Brazilian Journal of Physics



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### REFERÊNCIA

FERRAZ, A. C.; MIOTTO, R. Glycine adsorption on silicon (001). **Brazilian Journal of Physics**, v. 36, n. 2a, pp. 309-312, jun. 2006. DOI: <https://doi.org/10.1590/S0103-97332006000300020>. Disponível em: <https://www.scielo.br/j/bjp/a/5XM7xz8kypnMrYW8RtRYKQD/?lang=en#>. Acesso em: 10 set. 2021.

## Glycine Adsorption on Silicon (001)

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Received on 4 April, 2005

In this work we employ the state of the art pseudopotential method, within a generalized gradient approximation to the density functional theory, to investigate the dissociative adsorption process of glycine on the silicon surface. Our total energy calculations indicate that the chemisorption of the molecule is as follow. The gas phase  $\text{NH}_2\text{-C}_2\text{H}_2\text{-OOH}$  adsorbs molecularly to the electrophilic surface Si atom and then dissociates into  $\text{NH}_2\text{-C}_2\text{H}_2\text{-OO}$  and H, bonded to the electrophilic and nucleophilic surface silicon dimer atoms respectively, with an energy barrier corresponding to a thermal activation that is smaller than the usual growth temperature, indicating that glycine molecules will be observed in their dissociated states at room temperature. This picture is further support by our calculated vibrational modes for the considered adsorbed species.

Keywords: Glycine adsorption; Silicon (001); Density functional theory

### I. INTRODUCTION

In the past few years a great deal of effort has been devoted to the study of the adsorption and surface reaction mechanism of organic molecules on the silicon surface [1, 2]. The progress achieved in the incorporation of organic functionality onto semiconductor surfaces was not only related to the understanding of its fundamental aspects, but also to its importance in various technological applications, such as: insulator films, resist of nanolithography, chemical and biological sensors, and molecular electronics. As expected, each of these needs requires the development of a well defined organic layer on the semiconductor surface. As such organic layers are basically formed by exposing the semiconductor surface to organic compounds, the understanding of the first stages of the interaction between the surface and the organic structure is crucial in order to improve the quality of deposited layers. In this sense, the capability of predicting the functionalization process of a number of different radicals will facilitate the selection, or design, of organic molecules which bond to the silicon (001) surface in a specific manner, and therefore the production of new devices. This understanding can be achieved by the analysis of model systems, such as amino acids, in detail. In particular, glycine has both the carboxylic acid and amine functionalities, making it an excellent prototype for the interaction of more complex organic molecules with the silicon surface. Indeed, the adsorption of glycine on clean silicon (001) surfaces has been the subject of a recent vibrational study by Lopez and co-workers [3]. Their high-resolution electron Energy loss spectroscopy (HREELS) indicates that the chemisorption of glycine occurs through cleavage of the OH bonds in the carboxylic group. In this work we employ the state of the art pseudopotential method, within a generalised gradient approximation to the density functional theory, to investigate the adsorption process of glycine on the silicon (001) surface. A detailed analysis of the structural properties of possible adsorbed systems are discussed and compared to available experimental results, with a view to contribute to further investigations, and to the understanding and interpretation of more complex systems including aspects of biochemically

active thin films.

### II. THEORETICAL CONSIDERATIONS

The surface was modelled in a super-cell geometry, with an atomic slab of six Si layers and a vacuum region equivalent to eight atomic layers. The unit cell for the  $(2\times 2)$  surface structure is spanned by vectors  $\mathbf{a}_1 = a(1,1,0)$  and  $\mathbf{a}_2 = a(-1,1,0)$ . The theoretical value of the bulk Si lattice constant  $a$  was used in the surface calculations. On the top side of the slab we placed the glycine molecule in different configurations, and the back surface was passivated by H atoms arranged in a dihydride structure. Additionally, we made calculations for a single  $\text{NH}_2\text{-C}_2\text{H}_2\text{-OOH}$  molecule placed in a cubic box of 22 atomic units (a.u.) side. The pseudopotentials for Si, C, N, O and H were derived by using the scheme of Troullier and Martins [4] and the electron-electron exchange-correlation interactions were considered by using a generalised gradient approximation (GGA) [5] of the density functional theory. As for the surface calculations, the single-particle orbitals were expressed in a plane-wave basis up to the kinetic energy of 35 Ry. For the Brillouin-zone summation, four special  $\mathbf{k}$  points were used for surface calculations while for the isolated molecule we considered 8 special  $\mathbf{k}$  points. Increasing the energy cut-off to 50 Ry or the number of special  $\mathbf{k}$ -points to 16 did not result in total energy differences by more than 0.1%. The electronic and ionic degrees of freedom were relaxed by adopting the scheme described by Bockstedte *et al* [6]. The atoms were assumed to be in their fully relaxed positions when the forces acting on the ions were smaller than  $0.005 \text{ eV}/\text{\AA}$ . The most probable pathways and predicted energies from the gas-phase molecule to the adsorbed states were obtained by using a constraint dynamics scheme in which atomic movement along the pathway is a response to forces in a local region around it. The constraint is set only for the carbon (or hydrogen) atoms during the adsorption and dissociation processes. The energetic barriers are estimated following the phenomenological approach in the form of the Arrhenius equation [7] (for a more com-

plete description see Ref. [9]). The adsorption energy for the glycine molecule was calculated as  $E_{conf}^{ads} = -[E_{conf} - E_{ref}]$ , where  $E_{conf}$  is the total energy for the considered configuration,  $E_{ref}$  is the total energy for the free Si(001)-(2×2) surface plus the total energy for a free glycine molecule in a box of side 22 a.u.. The relaxed adsorption geometries were used to calculate the zone-centre vibrational modes within the frozen-phonon scheme [8]. For setting up the dynamical problem we considered the adsorbed system (the glycine molecule) and the Si dimer atoms.

### III. PRELIMINARY RESULTS

For bulk silicon our first-principles calculations produced 5.42 Å for the equilibrium lattice constant ( $a_0$ ), 0.86 GPa for the bulk modulus ( $BM$ ), and 4.39 eV for the cohesive energy, all in good agreement with the experimental values presented in Ref. [10]. The calculated theoretical lattice constant obtained for the bulk silicon is used in surface calculations. The clean Si(001)-(2×2) surface is characterised by alternated tilted Si-Si dimers, i.e. one dimer component is at a higher position than the other, but neighbouring dimers present opposing tilting directions. The tilting of the dimer allows charge transfer from the ‘down’ atom (which becomes more planar or  $sp^2$  bonded) to the ‘up’ atom (which becomes nearly pyramidal or  $s^2p^3$  bonded). Thus, the ‘down’ Si atom dimer is electron deficient, while the ‘up’ Si atom is electron rich. Our calculations support this model: the Si-Si dimer is found to have a bond length of 2.30 Å and a vertical buckling of 0.73 Å, indicating a tilt angle of 17.8°. To test the reliability of the carbon, nitrogen, and hydrogen pseudopotentials, we performed additional calculations. For cubic diamond we obtained 3.60 (3.57) Å, 4.53 (4.42) GPa and 7.28 (7.37) eV for the cubic lattice constant, bulk modulus, and cohesive energy, respectively, in good agreement with the experimental [10] values given in the parenthesis. Furthermore, our calculated bond lengths for the glycine molecule are C-C=1.58 Å, C-N=1.47 Å, N-H=1.03 Å, C-O=1.33 Å, C=O=1.37 Å, O-H=1.07 Å, and C-H=1.11 Å, in good agreement with available experimental data [10].

### IV. C<sub>2</sub>H<sub>5</sub>NO:SI(2×2)-(001) SURFACE

It is well established that the electron deficient (down) and electron rich (up) Si dimer atoms tend to react as electrophile and nucleophile, respectively. In general, the dissociative adsorption of electron-rich species (Lewis bases), such as H<sub>2</sub>O, is initiated by interaction with the electrophilic surface atom. As the NH<sub>2</sub>-C<sub>2</sub>H<sub>2</sub>-OOH molecule behaves like a Lewis bases, we expect it to initially adsorb on the electrophilic surface atom. Indeed we observe that glycine is adsorbed in a locally stable state, which then dissociate in NH<sub>2</sub>-C<sub>2</sub>H<sub>2</sub>-OO and H, with the H component bonded to the nucleophilic surface atom. These observations are in total agreement with the dissociative adsorption model proposed by Lopez and co-workers [3] for the chemisorption of glycine

on the silicon surface.

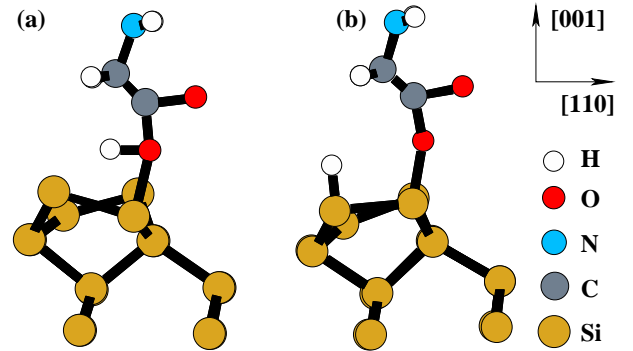


FIG. 1. Schematic views of the (a) molecularly (i.e. NH<sub>2</sub>-C<sub>2</sub>H<sub>2</sub>-OOH bonded at one side of the Si dimer) and dissociative (i.e. NH<sub>2</sub>-C<sub>2</sub>H<sub>2</sub>-OO and H bonded to different components of the dimer) adsorption models of glycine on Si(001)-(2×2).

In the following discussion, we are first going to address the equilibrium geometries for the glycine adsorbed species on the silicon surfaces in its molecular (i.e. NH<sub>2</sub>-C<sub>2</sub>H<sub>2</sub>-OOH bonded at one side of the Si dimer as in Fig. 1 (a)) and dissociative (i.e. NH<sub>2</sub>-C<sub>2</sub>H<sub>2</sub>-OO and H bonded to different components of the dimer as in Fig. 1 (b)) states, and then the chemisorption energetics. Our first-principles calculations predict an almost symmetric Si-Si dimer with a buckling of only 0.5° for the dissociatively case and an asymmetric dimer with a buckling of 13° for the molecularly adsorbed system. When the molecularly and dissociatively adsorbed systems are compared, we observe that the Si-Si dimer gets more elongated for the later than for the former. In our present calculations, the dimer is elongated by 6% for the dissociative case, but only 3% for the molecularly adsorbed case. This suggests that the Si-O bond is much stronger after the precursor dissociation occurs. This is further supported by the fact that the Si-O bond length is around 0.1 Å smaller for the dissociative adsorption model when compared to the molecular precursor state. Our data also suggests that, in general, both the NH<sub>2</sub>-C<sub>2</sub>H<sub>2</sub>-OOH and NH<sub>2</sub>-C<sub>2</sub>H<sub>2</sub>-OO adsorbed species retain the molecular gas phase characteristics, i.e. bond angle and bond lengths.

Our calculations suggest that the adsorption of the glycine molecule at the electrophilic surface (down) atom is an exothermic process, with an adsorption energy of 36 kcal/mol. Our constraint dynamics scheme suggests that this adsorption process involves an energy barrier around 18 kcal/mol. Considering the phenomenological approach in the form of the Arrhenius equation [7], with the choice for the A factor between 10<sup>13</sup>-10<sup>15</sup> s<sup>-1</sup>, we have estimated that, for complete dissociation (i.e., for a unitary reaction rate), an activation barrier of 18 kcal/mol corresponds to a thermal activation energy around 271 K. The molecularly adsorbed NH<sub>2</sub>-C<sub>2</sub>H<sub>2</sub>-OOH dissociates, then, in NH<sub>2</sub>-C<sub>2</sub>H<sub>2</sub>-OO and H, bonded respectively to the electrophilic and nucleophilic surface Si-Si dimer atoms, with an energy gain of 41 kcal/mol when compared to the precursor molecular adsorbed state. The corresponding dissociation reaction presents a barrier of 24 kcal/mol. This energy

TABLE I: Comparison of the key structural parameters for the free glycine molecule (glycine<sub>gas</sub>), and the molecular and dissociative adsorption models of glycine on the Si(001)-(2×2) surface. All bond lengths are in Å, while bond angles are in degrees. Si-Si represents the Si-Si dimer length for the adsorption site when the other dimer is unreacted.

bond length	glycine <sub>gas</sub>	molecular	dissociative
Si-Si		2.39	2.45
Si-O		1.84	1.73
Si-H			1.49
O-C	1.33	1.64	1.34
O-H	1.07	1.06	
O=C	1.19	1.17	1.21
C-C	1.58	1.53	1.55
C-N	1.47	1.40	1.44
C-H	1.11	1.10	1.10
N-H	1.03	1.02	1;03
bond angles		13	0.5
Si-Si		13	0.5
Si-Si-O		95	119
Si-Si-H			117
H-O-C	105		
O-C=O	119	116	123
O-C-C	113	116	116
C-C-N	124	126	123
H-C-H	105	104	104
H-N-H	107	108	107

barrier indicates that a thermal activation would lead the system into the dissociative chemisorption state. We have estimated that, for complete dissociation, an activation barrier of 24 kcal/mol corresponds to a thermal activation around 357 K. This is consistent with the fact that Lopez and co-workers [3] have only observed the NH<sub>2</sub>-C<sub>2</sub>H<sub>2</sub>-OO at room temperature.

In the next step of our study, we have studied the dynamical properties of both the molecular and dissociative adsorption models in order to establish each of them corresponds to the structure experimentally observed by Lopez and co-workers [3]. For calculating the zone-centre optical phonon modes we set up a 66×66 eigenvalue problem, and identified modes that describe pronounced surface character. The results of our calculations as well as available experimental data, for stretch and bending modes for the molecular and dissociative adsorption models are presented in Table II. In general, our results for the dissociative adsorption model are consistent with the observations by Lopez and co-workers [3] whose experimental data also suggest that this is probably the adsorbed species observed. As expected, for the majority of the calculated surface modes, the differences between the molecular and dissociative vibrational spectra are not relevant. The main difference between the two models (that might be detectable in a HREELS experiment) is the Si-H and Si-O stretch modes. The Si-O stretch mode is found to be 767 cm<sup>-1</sup> and 610 cm<sup>-1</sup> for the dissociative and molecular adsorbed structures respectively. The Si-H stretch mode of 2059 cm<sup>-1</sup>, on the other

TABLE II: Calculated vibrational modes for the dissociative and molecular adsorption models for the interaction of glycine with the Si(001)-(2×2). All values are in cm<sup>-1</sup>, and the indicated symbols for the vibrational modes are *s*=symmetric, *as*=antisymmetric, *st*=stretch, *scis*=scissors.

assignment	adsorbed structure		
	molecular	dissociative	exp. [3]
(NH <sub>2</sub> )s st	3534	3517	3460
(NH <sub>2</sub> )a st	3432	3429	3410
(CH <sub>2</sub> )s st	3120	3054	3040
(CH <sub>2</sub> )a st	2980	3014	2940
Si-H st		2059	2115
C=O st	1760	1724	1750
(NH <sub>2</sub> )scis	1545	1594	1620
(CH <sub>2</sub> )scis	1395	1383	1380
C-O st	1016	1146	1170
C=O bend	893	949	925

hand, is only observed for the dissociative adsorption model. Our calculated values for the dissociative adsorption model are consistent with the experimental values obtained by Lopez and co-workers [3] for the Si-H and Si-O stretch modes (2115 and 780 cm<sup>-1</sup>, respectively). As HREELS is one of the most accurate surface science techniques for the identification of the bonding nature, we believe that the experimental observations by Lopez and co-workers [3] combined with our first-principles calculations clearly indicate that the dissociative adsorption model is most likely to be the adsorbed structure.

## V. SUMMARY

We have performed first-principles calculations for the atomic structure and energetics of the adsorption of glycine on the silicon surface. Our data suggests that the global behaviour for the chemisorption of the glycine on the silicon surface is as follows: the gas phase NH<sub>2</sub>-C<sub>2</sub>H<sub>2</sub>-OOH adsorbs molecularly to the electrophilic surface Si atom and then dissociates into NH<sub>2</sub>-C<sub>2</sub>H<sub>2</sub>-OO + H, bonded to the electrophilic and nucleophilic surface silicon dimer atoms respectively, with an energy barrier corresponding to a thermal activation that is smaller than the usual growth temperature. This clearly indicates that glycine will be observed in its dissociated states at room temperature in agreement with the findings by Lopez and co-workers [3]. This picture is further supported by our vibrational mode analysis. The dissociative adsorbed state is found to be 77 kcal/mol more stable than the system composed by the molecular gas phase and the free silicon surface. Both the molecularly and dissociated adsorbed systems are characterised by elongated Si-Si dimers that are (almost) symmetric in the dissociative case but asymmetric in the molecular case. According to our first-principles calculations, the NH<sub>2</sub>-C<sub>2</sub>H<sub>2</sub>-OOH and NH<sub>2</sub>-C<sub>2</sub>H<sub>2</sub>-OO adsorbates retain the geometry observed for the gas phase glycine molecule.

**Acknowledgements**

The authors acknowledge financial support from the Brazilian agencies CNPq, CAPES, DPP-UnB.

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